

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	10/707704	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:24
L2	0	((charge near (trap or trapping) adj layer) with gate with (bottom adj electrode))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:25
L3	17	((charge near (trap or trapping) adj layer) with gate with (bottom adj (oxide or dielectric or insulating or insulator or insulation)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:26
L4	1	((charge near (trap or trapping) adj layer) with gate with (bottom adj (oxide or dielectric or insulating or insulator or insulation)) with (trench or via or hole))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:27
L5	1	((charge near (trap or trapping) adj layer) with gate with (bottom adj (oxide or dielectric or insulating or insulator or insulation)) with (trench or via or hole) with oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:27
L6	0	((charge near (trap or trapping) adj layer) with gate with (bottom adj (oxide or dielectric or insulating or insulator or insulation)) with (trench or via or hole) with sidewall)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:27
L7	4	((charge near (trap or trapping) adj layer) with gate with ((oxide or dielectric or insulating or insulator or insulation)) with (trench or via or hole) with sidewall)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:27
L8	15	(charge near (trap or trapping) near layer) with trench with sidewall	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:28
L9	7	((charge near (trap or trapping) near layer) with trench with sidewall).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:29

L10	15	((charge near (trap or trapping) near layer) with trench with sidewall)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:30
L11	0	(charge near (trap or trapping) near layer) near10 bottom near10 trench near10 conformal	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:30
L12	5	(charge near (trap or trapping) near layer) near10 bottom near10 trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:31
L13	24	(charge near (trap or trapping) near layer) near10 trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/09 19:31